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PATENT SPECIFICATION

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COMPLETE SPECIFICATION

Improved Materials for Polishing, Cleaning or the like and method of making the same

We, ALBERT BATCHELDER WELLS, CHANNING MCGREGORY WELLS, JOEL CHENEY WELLS, CHARLES OWEN COZZENS. CHARLES ELDRIDGE SPENCER, Juny, IRA 5 Mosher, Charles Newton Shelden, CHANNING MCGREGORY WELLS, Juny, GEORGE BURNHAM WELLS, JOHN MORSE WELLS, ALFRED TURNER WELLS and EDWARD ERNEST WILLIAMS, all Citizens 10 of the United States of America, constituting the American Optical Company, a voluntary association organized and existing by virtue of the laws of the State of Massachusetts and having a usual place of Massachusetts and naving a usual place or 15 Lusiness at 14, Mechanic Street, South-tridge, Massachusetts, United States of America, do hereby declare the nature of this invention and in what manner the same is to be performed, to be particularly 20 described and ascertained in and by the following statement: -

This invention relates to the provision of novel materials suitable for polishing, cleansing, purifying, use as catalysts or 25 catalyst carriers, or other purposes and

process of making the same.

One of the principal objects of the invention is to provide a fine grain material with a relatively large available 30 surface suitabe for various mechanical and chemical uses.

Another important object of the invention is to provide a non-toxic and non-

pigmenting polishing material.

Another important object of the invention is to provide a composition of matter which is a substitute for commercially known rouge (iron oxide) which has been the almost universal polishing medium, 40 particularly for glass polishings, which does not stain or discolour objects with which it comes in contact, such as skin, clothing, furniture, buildings, floors, etc.; which does not constitute a health hazard, 45 which is relatively low in cost, and which imparts a polish of high quality within a reasonable time, and which is generally acceptable for commercial use as regards the texture of the polished surface.

Other objects and advantages of the invention should become apparent from

the following description.

Considering said materials as polishing means, it has been usual in the past, in forming highly polished surfaces on giass 55 or the like, to use an iron oxide known commercially as rouge. Although this rouge is practical, as regards its polishing characteristics, it has a decidedly undesirable staining nature, particularly as 60 regards the clothing of the operator using such rouge, and the machinery, floors, ceilings or other parts of the building in which such polishing operations are canried on.

Many attempts have been made to overcome the disadvantages of rouge and yet attain its desirable polishing characteristics through the use of substitute polishing materials. One of these 70 polishing materials has been made of finely powdered silica because it does not stain. Silica, however, proved inferior to rouge, as regards its polishing characteristics and the type of polish obtained 75 on the surfaces of glass articles. In addition to the above difficulties, silica has a decided disadvantage in that its use now

decided disadvantage in that its use may involve a serious health hazard.

One of the prime objects, therefore, of 80 the present invention is to completely overcome the above difficulties, as regards toxic and pigmenting conditions, through the provision of non-toxic and non-pigmenting polishing materials possessing 85 one or more of the above characteristics and to provide fine grain materials adaptable to many other uses.

In accordance with this invention there is provided a process of making a material 90 suitable for use as a polisher, a cleanser, a purifier, a catalyst, a catalyst carrier or other purposes, which comprises forming a fine grained non-toxic, non-staining material having a physical state that will 95 polish glass without scratching by heating a batch of kaclinic clay so as to remove the water of hydration without sintering of the particles under the fluxing action of the water and continuing the heating 100 for a time interval sufficient to heat the individual particles of clay to a tempera-ture between 1000° and 2100° F., the temperature used in said treatment,

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according to the particular batch of clay, being within said range and adjacent to but below the temperature which will cause an appreciable portion of said clay to sinter into hard lumps, in which case it would lose its effectiveness as a glass polisher as compared with rouge.

The temperature used may be determined by heat treatment of said clay to 10 different temperatures within the said range and by trial glass polishing with the materials produced at said different temperatures, whereby a temperature is determined which gives a material having the maximum non-scratching efficiency, surface quality producing nature, and a speed of operation substan-

tially equal to that of rouge.

The invention also includes materials 20 when prepared or produced by the process described above. Particularly useful materials can be obtained by heating the individual particles of the kaolinic clay

individual particles of the kaolinic clay to a temperature between 1300° and 25 1600° F. and between 1500° and 1600° F.

It will be apparent that many changes may be made in the arrangements and methods shown and described without departing from the scope of the invention as expressed in the accompanying claims. It, therefore, is to be understood that the invention is not limited to the specific arrangements and methods

to the specific arrangements and methods shown and described, as the preferred 35 forms only have been given by way of illustration.

Referring to the drawing:

The figure of the drawing shows a typical time-temperature diagram giving 40 the corresponding temperatures of the material and of the furnace as heating progresses for a specified preferred material embodying the invention and indicating the temperature ranges in 45 which various conversions takes place for the given material and indicating the maximum temperature of heating according to the distinct of the size of the si

ing to this invention

For ease in describing the present 50 invention, it will be described as applied to polishing materials, although its use is not limited thereto. In setting forth the preferred form of the invention, a Kaolinic clay is selected from a suitable

55 source of supply, as for example, from Florida or Georgia, which clay is commercially known as Florida Kaolin or Georgia Kaolin. Kaolin is favoured because of its freedom from sand, grit, 60 etc. It is to be understood, however, that kaolinic clay from many sources may be used, requiring in some instances, purious description.

used requiring in some instances, purification preceding or subsequent to the heat treatment

65 The Kaolinic clay passes through

several well defined stages during the heat treament. Theoretically these seem to be as follows:

First, during the initial heating of from room temperature to about 850° F., the 70 mechanical and hygroscopic water is eliminated.

Secondly, the chemically combined water, the 2H₂O of the clay Al₂O₃. 2SiO₂. 2H₂O, is evolved or 75 vaporized by an endothermic reaction (heat absorbing). Care should be exercised to separate this water of hydration without too rapid elevation in temperature so as to avoid sintering of 80 particles together by the possible fluxing action of the water. Therefore, at the second stage, between 900° to 1100° F. this 2H₂O should be substantially eliminated.

Thirdly, the heating is continued to break up the structure of the aluminium silicate to reduce it to the desired condition. Practical temperatures will be discussed later. At this stage the clay is 90 reduced to a practical polishing material with the exception that perhaps some large aggregates might be present. These, however, are easily broken down through subsequent treatment, as by milling, tolling or the like. It is important, that the third stage of heating be not carried too far as the material will then not produce as good a poished surface.

The material resulting from the third 100 stage of the heating is available as a crude polishing compound. It may be rendered polishing compound. It may be reintered still finer in texture, as by grinding or in any other manner breaking up the adherence between particles. It is, in 105 general, desirable to thus improve the quality of the material, as these adhering particles if not broken down, tend to scratch the surface which is being polished by said material due to mechanical action. 110 The limiting of the temperature to which the heating is carried, in this third stage, is important, as above set forth. It has been found that above 2100° F, the change into an undesirable structure begins to 115 take place very rapidly so that the clay should not be heated above 2100° F. The temperature need not be carried as high as 2100° F. in order to effect the desirable transformation, as this action begins to 120 take place at about 1000° F. Within the range of 1000° to 2100° F., the desired transformation takes place more rapidly and more completely as the temperature is elevated.

It has been found, through the use of samples of clay which have been prepared and tested by the standard tests to evaluate polishing compounds, that the quality of polish obtained can be very well 180

explained by the weight of glass which is removed from test glass and by a general description of the appearance of the surface. In this test, a flat disc of glass is possibled for ten minutes with the material under test under standard carefully controlled conditions. The table which

follows sets forth some general results on a specific material, commercially known as United Clay Mines "Putnam Clay", 10 a Florida Kaolin. Successive batches were held at the indicated temperatures for two hours, milled, and then given the standard polishing test.

15	Calcination for a Two	Temperature Hour Period	Removal Rate in mg. per Ten Minutes Stan- dard Polishing Test	Surface Quality
	482° C.	(900° F.)	4.2	Poor
	5 38	(1000°)	15.6	
20	593	(1100°)	30.8	· Fair
	648	(1200°)	38.4	
	70 4	(1300°)	41.0	Hood
	760	(1400°) ·	44.4	
•	815	(150 0°)	45.6	,,
25	871	(1600°)	: 43.2	. ,,
•	926	(1700°) .	36.0	Fair
	981	(1800°)	37.2	
	1036 _	(1900°)	36.0	" -
	1093	(3000°)	45.4	Pour
30	1204	(3200°)	58.6	
	1315	(2400°)	57.2	,,
	1427	(2600°)	54.0	3,1
	1510	(2750°).	53.4	••
			. 00.4	••

It will be noted, by the chart set forth above, that as calcination is stopped at 100° F. intervals between the 900° F. and 1500° F. the rate of removal and quality of the polished surface increases steadily to a maximum. It will be noted that from 40 900° to 1100° F. the surface quality is poor and rate of removal is relatively low. From 1100° F. to 1300° F., the rate of removal increases and the surface quality is better. From 1300° F to 1600° F. the 45 removal rate is relatively high and the surface quality good. The surface quality, however, between 1600° F. and 1700° F. commences to fall off and the removal rate also diminishes. This reduction of removal rate and change of surface quality from good to fair continues to approximately 1900° F. where upon the surface quality then decreases to a very poor state although the rate of removal increases. This increased rate of removal is probably due to the crystalline structure which the material develops at such high temperature. By comparison of these removal rates, with the removal rates of the best polishing rouges, it is found that they are of the same order of magnitude. The polishing material, however, as produced by clay treated as specified above is nontoxic and non-pigmenting and is in this manner more desirable tha rouge. Other Raolinic clays have given even

better results.

The duration of heating at the tem-

perature chosen does not seem to be a very important factor beyond a reasonable time. Equivalent removal rates and surface quality were obtained whether the clay was held at the maximum temperature of calcination for two hours or for several days. Of course, the necessary length of time depends on how large a bulk of material is being heated and how easily the temperature gradient from the outside to the interior of the mass is smoothed out or equalized. As evidence for this point of consideration, batches of Florida Raolinic clay were held at 1500° F. (815° C.) for the times given, as illustrated in the table below.

	Rate of Removal in mg. per Ten		85
Time in Hours	Minutes Standard Polishing Test	Surface Quality	. •
0.5 1.2 2 4 8 24	47.2 51.0 52.0 58.4 56.8 57.2	Fair to good Good '', Fair to good	90

If the heat is prolonged for too long a 95 time the formation of some undesirable hard material seems to take place.

hard material seems to take place.

The material obtained at 1500° F. (815° C.) is very soft and fine-grained, but the particles do remain in friable 100

lumps which must be broken up by some

To effect this breaking up suitable ballmilling or the like may be employed. The milling process may be carried on either wet or dry. It has been found, however, that wet milling is more desirable from the standpoint of avoiding caking up with the result that a more rapid milling action 10 takes place. The material may be used in this condition or may be subjected to a subsequent drying process. It is impor-tant to note that although a wet milling is employed the clay does not real sorb the 15 liquid used in the milling process and decrease its polishing ability, that is, it does not have any tendency to return to its initial state; Al₂O₃. 2SiO₂. 2H₂O. Samples of said material have been 20 retained in water for many months with-

out deteriorating its polishing ability.

The time of milling depends upon the size and charging of the mill. It should be continued at least long enough to 25 reduce all of the material to finer than 200 mesh, which is a standard accepted term

used in screening

Georgia and Florida Raolinic clays are particularly suitable for use but other 30 kaolinic clays may be used. It is to be understood, therefore, that the Raolinic clays given here are only given by way of illustration.

The temperature controls and treat-35 ments given herein are set forth for rendering the various materials usable as polishing ingredients and such treat-ments may also apply for rendering the materials practical for other uses. In 40 following out this treatment suitable temperature control must be obtained. For ease of description the temperature controls of a particular clay (Florida Kaolin) have been given but it is to be understood 45 that anyone skilled in the art could apply these teachings to other kaolinic clays.

In following the steps of this heat treatment and in order to arrest it at the optimum point any of the techniques
50 familiar in ceramic technology may be
used. For the purposes set forth, the final test is always how the material will polish glass, but when the material is to be used for other purposes, other means for determining the optimum temperature for arresting the calcination may be desirable among which may be mentioned the contraction. changes in index of refraction, specific gravity, in the X-Ray diffraction pattern, 60 in the bulk weight, and the tendency to One of the most used and rehydrate. simpler methods for following the course of calcination is by measuring the differential rate of heating. In this 65 method the clay, in a suitable container,

is placed in a furnace. A thermocouple is embedded in the clay or other material and the temperature changes measured in comparison to that of the furnace as the temperature of the furnace is raised at a 70 constant rate. This is diagrammatically illustrated in the figure of the drawing by a chart showing the differences in temperature. The temperatures of a Florida Kaolin and the furnace in which it was 75 heated are recorded at different time intervals for the duration of the heating. Referring to the curve A of the chart it may be seen that the maximum endo-thermic (heat absorbing) reaction takes 80 place at about 600° C. (1100° F.) after 70 minutes of total heating time. The evolution of heat takes place at about 1100° C. (2000° F.) in 85 minutes, as illustrated at P on the chart; therefore, 85 the temperature to which this material should be heated to obtain the optimum properties desirable for this purpose described is probably somewhat below 1100° C. (2000° F.) let us say 925° to 1000° C. 90 (1760° to 1850° F.). The curve A illustrates the temperature of the thermocouple which is embedded in the clay, the curve B illustrates the temperature of the thermocouple which is freely exposed to 95 the furnace atmosphere. From curves of this type the desired maximum temperature of calcination can be determined. The finding of this method should then be checked by actual service test and con- 100 rected according to the results of said test.

Although the invention has been described as for use in polishing glass articles, materials, resulting from this invention may be used for many other 105 purposes such as a substitute for pumice to eliminate the scratching characteristics of pumice; for use in touthpaste; for use in purifying oils and other liquids in a manner for which charcoal or like is used; 110 for use as filter means; for use in impreg-nating felt to produce dust filters; for use as a solid adsorbent either in granular form or by bricketing; for use as a catalyst or carrier for catalysts; and for many 115 other purposes.

In general it is desirable to obtain such a material that has no pigment so it will not stain, and also that is not toxic so it will not be a health hazard.

The procedure is to treat the clay, by heating it to a definite temperature that has been proven by test or trial to be the optimum, and then further treating it to break down adhering particles. The 125 consideration is to heat treat the material to a temperature that has been proven by trial or test to produce the best polishing results. The proper temperature and exposure for any material under con- 130

sideration is obtained emphatically by test and trial for that particular material.

The heat is applied snowly through the temperature at which the water mechanically head comes off, so that the grains of material remain as discrete grains that will not melt or sinter together.

The controlling factor is whether or not the material so operated upon proves on 10 test to be adaptable for the results required. The limits of operation are emphatically determined as has been stated above.

From the foregoing description it will 15 be seen that a simple, efficient and economical means and methods have been provided for accomplishing all of the objects and advantages of the invention.

Having now particularly described and 20 ascertained the nature of our said invention and in what manner the same is to be performed, we declare that what we claim is:—

1. A process of making a material suitable for use as a polisher, a cleanser, a purifier, a catalyst, a catalyst carrier or other purposes, which comprises forming a fine grained non-toxic, non-staining material having a physical state that will 30 polish glass without scratching by heating a batch of kaolinic clay so as to remove the water of hydration without sintering of the particles under the fluxing action of the water and continuing the heating for 35 a time interval sufficient to heat the individual particles of clay to a temperature between 1000° and 2100° F., the temperature used in said treatment, according to the particular tatch of kaolinic clay 40 being within said range and adjacent to but below the temperature which will cause an appreciable portion of said clay to sinter into hard lumps.

A process as claimed in Claim 1,
 wherein the temperature used is determined by heat treatment of said clay to

different temperatures within the said range and by trial giass polishing with 50 the materials produced at said different temperatures, wherety a temperature is determined which gives a material having the maximum non-scratching efficiency, surface quality producing nuture, and a 55 speed of operation substantially equal to that of rouge.

3. A material suitable for use as a polisher, a cleanser, a purifier, a catalyst, a catalyst carrier or other purposes when 60 prepared or produced by the process claimed in Claim 1 or Claim 2.

4. A material as claimed in Claim 3, when obtained by heating the individual particles of the kaolinic clay to a tem- 65 perature below 1300° and 1600° F.

5. A material as claimed in Claim 3, when obtained by heating the individual particles of the kaolinic clay to a temperature of approximately 1500° F. to 70 1600° F.

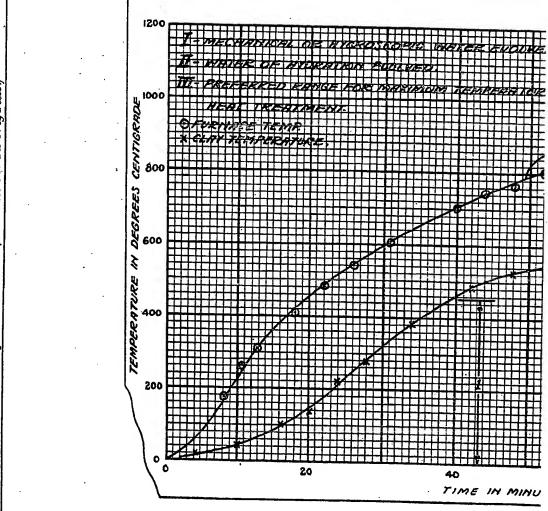
6. The process for preparing or producing polishing materials substantially as hereinbefore described.

7. Polishing materials when prepared 75 or produced by a process substantially as hereinbefore described.

Dated this 30th day of April, 1940.
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Per: —Boult, Wade & Tennant, 112. Hatton Garden, London, E.C.1, Chartered Patent Agents.

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This Drawing is a full-size reproduction of the Orinina!

